

# CYPRESS SEMICONDUCTOR

## PRODUCT CHANGE NOTIFICATION

**PCN:**020015

**DATE:** May 14, 2002

**Subject:** Network Search Engine, Fab Location Change

**To:**

**Description of change:**

The part number listed below has been qualified to be transferred from IBM Fab in Essex Junction, Vermont to TSMC Fab in Hsin Chu, Taiwan using the same fab process and die revision. This change was initiated by the planned phase out of the previously qualified IBM Fab. No changes have been made that effect form, fit, or function and no changes will be made to the data sheet or part number. Device markings will be modified to include an "A" in the part number to denote devices manufactured under the TSMC process. Qualification report QTP# L000006 is attached.

**Cypress part numbers affected:**

<b>IBM Part Number</b>	<b>New TSMC Part Number</b>
CYNSE70064-50BGC	CYNSE70064A-50BGC
CYNSE70064-66BGC	CYNSE70064A-66BGC
CYNSE70064-83BGC	CYNSE70064A-83BGC

**Customer part numbers affected:**

**Modified as indicated above**

**Benefit of change:**

Better support and cycle time.

**Qualification status:**

Complete. Qualification report QTP# L000006 is attached.

**Sample status:**

Contact our local sales office.

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**DATE:** May 14, 2002

**Subject:** Network Search Engine, Fab Location Change

**Sample status:**

Contact our local sales office.

**Approximate Implementation Date:**

Production release of the new material will be phased in immediately.

**Response Required:**

*Fax signed approval to Al Laxman at 408-943-2165 or reply by E-mail.  
For any additional information regarding this change, contact your local sales representative.*

Sincerely,

Mike Burke  
Director of QA

Al Laxman  
PCN Manager

# Cypress Semiconductor Product Qualification Report

QTP# L000006 VERSION 1.0  
April, 2002

<p>CYNSE70064A 2Meg, Network Search Engines 0.18um Technology, Fab TSMC</p>
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## CYPRESS TECHNICAL CONTACT FOR QUALIFICATION DATA:

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Reliability Director  
(408) 432-7069

Al Laxman  
Quality Engineering  
(408) 545-7120

PRODUCT QUALIFICATION HISTORY

<b>Qual Report</b>	Description of Qualification Purpose	<b>Date Comp</b>
L000005	New Technology 0.18um, TSMC Fab / New 4 Meg, NSE, Device CYNSE70128	Apr 02
L000006	2 Meg NSE, Device CYNSE70064A	Apr 02

<b>PRODUCT DESCRIPTION (for qualification)</b>			
Qualification Purpose: Qualify New 2Meg, NSE CYNSE70064A, 0.18um Technology at TSMC Fab.			
Marketing Part #:	CYNSE70064A-83BGC / CYNSE70064A-66BGC / CYNSE70064A-50BGC (Lara Network part # LN17020A-083 / LN17020A-066 / LN17020A-050)		
Device Description:	2Meg, NSE device		
Cypress Division:	Cypress Semiconductor Corporation –Data Communication Division (DCD)		
Overall Die (or Mask) REV Level (pre-requisite for qualification):		Rev. B	
Die Size (stepping):	265 mils x 452 mils	What ID markings on Die:	LN7802MAR

<b>TECHNOLOGY/FAB PROCESS DESCRIPTION</b>			
Number of Metal Layers:	5	Metal Composition:	1-5: Al Cu
Passivation Type and Materials:	Oxide / Nitride		
Free Phosphorus contents in top glass layer(%):	0%		
Number of Transistors in Device	50 million		
Number of Gates in Device	20 million		
Generic Process Technology/Design Rule ( $\mu$ -drawn):	CMOS, 5Metal layer, 0.18um		
Gate Oxide Material/Thickness (MOS):	SiO <sub>2</sub> 32Å / 70Å		
Name/Location of Die Fab (prime) Facility:	TSMC Taiwan		
Die Fab Line ID/Wafer Process ID:	TSMC Fab 4 / CL018G		

#### PACKAGE AVAILABILITY

<b>PACKAGE</b>	<b>ASSEMBLY SITE FACILITY</b>
<b>272-ball HSBGA</b>	<b>ASE Taiwan</b>

**Note:** Package Qualification details upon request

**MAJOR PACKAGE INFORMATION USED IN THIS QUALIFICATION**

<b>Package Designation:</b>	BG272
<b>Package Outline, Type, or Name:</b>	272-ball Heat Sink Ball Grid Array (HSBGA)
<b>Manufacturer / Mold Compound Name:</b>	Toshiba KE-1100A
<b>Mold Compound Flammability Rating:</b>	V-0 per UL94
<b>Oxygen Rating Index:</b>	>28%
<b>Substrate Material:</b>	BT Resin
<b>Lead Finish, Composition / Thickness:</b>	Solder Ball, 63%Sn, 37%Pb
<b>Die Backside Preparation Method/Metallization:</b>	N/A
<b>Die Separation Method:</b>	Wafer Saw
<b>Die Attach Supplier:</b>	Ablestik
<b>Die Attach Material:</b>	8355F
<b>Bond Diagram Designation:</b>	K-B-ASE-0272B8A-01 Rev A
<b>Wire Bond Method:</b>	Thermosonic
<b>Wire Material/Size:</b>	Au / 1.0 mil
<b>Thermal Resistance Theta JA °C/W:</b>	14.6°C/W
<b>Package Cross Section Yes/No:</b>	N/A
<b>Assembly Process Flow:</b>	ASE SPEC# 64-04-000-0348
<b>Name/Location of Assembly (prime) facility:</b>	ASE Taiwan

**ELECTRICAL TEST / FINISH DESCRIPTION**

<b>Test Location:</b>	ASE Taiwan
<b>Fault Coverage:</b>	100%

**RELIABILITY TESTS PERFORMED PER SPECIFICATION REQUIREMENT**

Stress/Test	Test Condition (Temp/Bias)	Result P/F
High Temperature Operating Life Latent Failure Rate	Dynamic Operating Condition, 125°C Vcc 1.8V=2.2V Vcc 3.3V=3.3V	P
Electrostatic Discharge Human Body Model (ESD-HBM)	2,000V MIL-STD-883, Method 3015.7	P
Electrostatic Discharge Charge Device Model (ESD-CDM)	500V	P
Static Latchup Sensitivity	25C to 100C, > ±200mA	P

## RELIABILITY FAILURE RATE SUMMARY

Stress/Test	Device Tested/ Device Hours	# Fails	Activation Energy	Thermal AF <sup>4</sup>	Failure Rate
High Temperature Operating Life Early Failure Rate	N/A	N/A	N/A	N/A	N/A
High Temperature Operating Life <sup>1,2</sup> Long Term Failure Rate	360,000	0	0.7	N/A	46 FIT

<sup>1</sup> Assuming an ambient temperature of 55°C and a junction temperature rise of 15°C.

<sup>2</sup> Chi-squared 60% estimations used to calculate the failure rate.

<sup>3</sup> Thermal Acceleration Factor is calculated from the Arrhenius equation

$$AF = \exp \left[ \frac{E_A}{k} \left[ \frac{1}{T_2} - \frac{1}{T_1} \right] \right]$$

where:

$E_A$  = The Activation Energy of the defect mechanism.

$k$  = Boltzmann's constant =  $8.62 \times 10^{-5}$  eV/Kelvin.

$T_1$  is the junction temperature of the device under stress and  $T_2$  is the junction temperature of the device at use conditions.



## Accelerated Lifetime Tests

### High Temperature Operating Life (HTOL)

Test	LOT#	Temp. Cycle	Bias	Sample Size	Duration	Result Pass/Fail
HTOL	DB5399	125°C	Vcc 1.8 = 2.2V Vcc 3.3 = 3.3V	120	1000hrs	120/0
HTOL	DB5961	125°C	Vcc 1.8 = 2.2V Vcc 3.3 = 3.3V	120	1000hrs	120/0
HTOL	DB5962	125°C	Vcc 1.8 = 2.2V Vcc 3.3 = 3.3V	120	1000hrs	120/0

### Human Body Model (HBM)

Test	Test Vehicle	Temp. Cycle	Bias	Sample Size	Duration	Result Pass/Fail
HBM	TV1	Ambient	2.0K Volts	4	COMP	4/0

### Charge Device Model (CDM)

Test	Test Vehicle	Temp. Cycle	Bias	Sample Size	Duration	Result Pass/Fail
CDM	TV1	Ambient	>0. 5K Volts	6	COMP	6/0

### Latch-up

Test	Test Vehicle	Temp. Cycle	Bias	Sample Size	Duration	Result Pass/Fail
Latch-up	TV1	25°C to 100°C	> ± 200mA	2	COMP	2/0